

Title (en)
METHOD FOR MAKING A TFT ACTIVE MATRIX FOR A PROJECTION SYSTEM SCREEN

Title (de)
VERFAHREN ZUR HERSTELLUNG EINER AKTIVEN TFT-MATRIX FÜR EIN PROJEKTIONSANZEIGESYSTEM

Title (fr)
PROCEDE DE FABRICATION DE MATRICE ACTIVE TFT POUR ECRAN DE SYSTEME DE PROJECTION

Publication
EP 0819263 A1 19980121 (FR)

Application
EP 96912073 A 19960405

Priority
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Abstract (en)
[origin: WO9631799A1] A method for making a liquid crystal display active matrix with four masking levels where the control transistors are of the top-gate type. The resulting liquid crystal display is particularly suitable for use in projection display systems. The method comprises, inter alia, the steps of depositing and etching a first opaque level (1) on a transparent insulating plate (2); depositing an insulating transparent film (3); depositing and etching a transparent conductor (7); selectively depositing an ohmic contact then depositing an intrinsic semiconductor material and a gate insulator (8), and performing a first etching of the resulting assembly; depositing and etching an opaque conductive level (9); and performing a second etching of the semiconductor (7) and gate insulator (8) level using the mask of the opaque conductive level (9).

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G02F 1/136; **G02F 1/1335**; **H01L 27/12**; **H01L 21/84**

IPC 8 full level
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